

NICKEL TITANIUM

Sputtering Target

NS6130-10-1350

Quick Facts

Product	:	Nickel Titanium Sputtering Target
Stock No	:	NS6130-10-1350
Purity	:	99.99%
Molecular Formula	:	Ni-Ti
Form	:	Solid

Technical Specification

Diameter	Thickness
76.2mm	2mm

Nickel titanium sputtering targets are commonly used in the production of shape memory alloys, as well as in medical devices such as stents and orthodontic wires. They are also used in aerospace, automotive, and other industries. Sputtering targets are usually made of high-purity metals or compounds and are used to create a wide range of materials, including semiconductors, optical coatings, and magnetic films.

* This image is for graphic purposes only and does not represent the actual product.

